<u> </u>			No. of the last of	ee)			Sheet 1 of	1 sneets	
U.S. Department of Commerce, atent and Trademark Office					Docket No.		Serial No.		
						AMAT/6392/DSM/LO W K/JW		10/010,950	
SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT BY APPLICANT						Applicant Xia, et al.		Confirmation No. 5694	
(Use several sheets if necessary) (December 1					Filing Date		Group		
Examiner Dung Anh Le					Novembe	November 13, 2001		2818	
U.S. Paten	t Docu	ments		A TRAINEM PON ON	<u> </u>		·		
*Examiner Initial		Document Number	Issue Date	Applicant(s) Name	Class	Subclass	Filing Date If Appropriate	f	
Dle	A1	6,455,445 B2	09/24/2002	Matsuki	438	789	03/28/2001		
	A2	6,436,824 B1	08/20/2002	Chooi, et al.	438	687	07/02/1999		
	А3	6,432,846 B1	08/13/2002	Matsuki	438	790	10/18/2000		
	A4	6,410,463 B1	06/25/2002	Matsuki	438	790	10/18/2000		
	A5	6,383,955 B1	05/07/2002	Matsuki, et al.	438	790	06/07/1999		
	A6	6,352,945 B1	03/05/2002	Matsuki, et al.	438	778	06/07/1999		
	A7	6,344,693 B1	02/05/2002	Kawahara, et al.	257	759	05/17/2000		
	A8	6,242,339 B1	06/05/2001	Aoi	438	623			
	A9	6,060,132	05/09/2000	Lee	427	579	06/15/1998		
	A10	5,554,570	09/10/1996	Maeda, et al.	437	235	01/09/1995		
	A11	4,894,352	01/16/1990	Lane, et al.	437	238	10/26/1988		
	A12	2002/0160626 A1	10/31/2002	Matsuki, et al.	438	780	04/25/2002		
l	A12	2002/0111042 A1	08/15/2002	Yau, et al.	438	789	11/15/2001		
Foreign Pa	tent D	ocuments							
*Examiner		Document Number	Date	Country	Class	Subclass	Translation		
Initial							YES	NO	
1)	B1	99/41423	08/19/1999	WO	C23C	A2			
	B2								
OTHER AF	RT								
*Examiner Initial		Including Author, Pertinent Pages, I							
Dh	C1	U.S. Patent Application: 09/638,803;filed on August 12, 2000; Method of Depositing Organosilicate Layers							
	C2								
	C3								
Examiner	aminer) ω					Date Considered 5/03			
				ot citation is in confo e copy of this form w				ugh	